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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/586,361	07/18/2006	David Ezra	3003-1183	2968
466	7590	01/05/2009	EXAMINER	
YOUNG & THOMPSON			PRITCHETT, JOSHUA L	
209 Madison Street				
Suite 500			ART UNIT	PAPER NUMBER
ALEXANDRIA, VA 22314			2872	
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary	Application No.	Applicant(s)	
	10/586,361	EZRA, DAVID	
	Examiner	Art Unit	
	JOSHUA L. PRITCHETT	2872	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) Responsive to communication(s) filed on 20 November 2008.
 2a) This action is FINAL. 2b) This action is non-final.
 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) Claim(s) 1-34 is/are pending in the application.
 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
 5) Claim(s) _____ is/are allowed.
 6) Claim(s) 1-34 is/are rejected.
 7) Claim(s) _____ is/are objected to.
 8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) The specification is objected to by the Examiner.
 10) The drawing(s) filed on 18 July 2006 is/are: a) accepted or b) objected to by the Examiner.
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 a) All b) Some * c) None of:
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____ . |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application |
| Paper No(s)/Mail Date _____. | 6) <input type="checkbox"/> Other: _____ . |

DETAILED ACTION

This action is in response to Request for Continued Examination and Amendment filed November 20, 2008. Applicant amended claims 1 and 21 and added claims 33 and 34.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 2, 5, 8, 10, 12, 13, 15-18, 20-23, 33 and 34 are rejected under 35 U.S.C. 102(b) as being anticipated by Knop (US 4,251,137).

Regarding claims 1 and 21, Knop discloses an encoding surface (302) having a micro-relief pattern having a predetermined spatial distribution thereby (Figs. 3a-b) to produce a predetermined diffracted first image when illuminated in use (col. 2 lines 50-55), and an optically anisotropic layer (304) of liquid crystal material located over the encoding surface (abstract; col. 2 lines 65-66) wherein at least part of the micro-relief pattern induces local orientation of the optical axis of the optically anisotropic layer (Fig. 3b; col. 3 lines 12-27) to align the local optical axis at respective orientations corresponding to the predetermined spatial distribution of the micro-relief pattern to impose a predetermined polarization modulation to

produce a predetermined polarized second image when illuminated in use so that both a diffracted image and a polarized image are viewable in which both the diffracted image and the polarized image vary spatially across at least part of the overall image (MPEP 2114)..

Regarding claims 2 and 22, Knop discloses the micro-relief pattern is provided on a layer in contact with the optically anisotropic layer thereby to define the encoding surface (Figs. 3a-b).

Regarding claim 5, Knop discloses the encoding surface includes a plurality of area each of which having a respective orientation of the micro-relief pattern thereon defining respective optical axes of the optically anisotropic layer (Figs. 3a-b).

Regarding claim 8, Knop discloses the average thickness of the optically anisotropic layer and its birefringence varies with position across the device to vary the optical retardation induced thereby (col. 5 lines 12-30).

Regarding claim 10, Knop discloses the thickness of the optically anisotropic layer disregarding the micro-relief pattern is generally continuously contoured (Figs. 3a-b).

Regarding claim 12, Knop discloses the encoding surface is reflective over at least part of the device whereby at least part of the device is adapted to operate in reflection mode (col. 1 lines 25-30).

Regarding claim 13, Knop discloses at least part of the surface of the optically anisotropic layer remote from the encoding surface is at least partially reflective (col.1 lines 25-30).

Regarding claim 15, Knop discloses use in transmission mode (col. 1 lines 25-30).

Regarding claim 16, Knop discloses us in reflection mode (col. 1 lines 25-30).

Regarding claim 17, Knop discloses the optically anisotropic layer comprises a polymerisable liquid crystalline material (abstract).

Regarding claim 18, Knop discloses the optically anisotropic layer comprising a polymer liquid crystal material (abstract).

Regarding claim 20, Knop discloses the refractive index of the micro-relief layer is substantially equal to the ordinary or extraordinary refractive index of the optically anisotropic layer (col. 1 lines 25-30). If the diffraction system is not a refraction modulation system then a substantial difference in the refractive indices would create undesired reflections at the interface.

Regarding claim 23, Knop discloses the micro-relief pattern is formed by embossing (col. 1 lines 45-50).

Regarding claims 33 and 34, Knop discloses the liquid crystal material has a planar orientation with the optical axis lying substantially parallel to the encoding surface and the optical axis following directions of the predetermined distribution of the micro-relief pattern (Fig. 3b)

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 3, 4, 14, 19 and 24-32 are rejected under 35 U.S.C. 103(a) as being unpatentable over Knop (US 4,251,137) in view of Suzushi (US 2002/0110651).

Regarding claim 3, Knop teaches the invention as claimed but lacks reference to forming the encoding surface on the anisotropic layer. Suzushi teaches the encoding surface is formed on the optically anisotropic layer (para. 0053). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include the location of the encoding surface for the purpose of allowing the device to adjust the diffractive performance and the polarization performance of the incident light at the same point.

Regarding claim 4, Knop teaches the invention as claimed but lacks reference to forming multiple regions. Suzushi teaches the encoding surface includes one or more regions having a significant diffractive effect and one or more relatively weakly diffractive regions where there is little or no diffractive effect (para. 0026). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include the multiple regions for the purpose of affecting different incident light in different manners.

Regarding claim 14, Knop teaches the invention as claimed but lacks reference to a reflective substrate. Suzushi teaches the micro-relief layer comprises a transmissive substrate and at least part of the surface thereof remote from the interface with the optically anisotropic layer is reflective (para. 0009, 0025). It would have been obvious to one of ordinary skill in the

art at the time the invention was made to have the Knop invention include the reflective substrate of Suzushi for the purpose of creating an image on the same side of the device as the light source.

Regarding claim 19, Knop teaches the invention as claimed but lacks reference to a fixing process. Suzushi teaches the optically anisotropic layer is permanently preserved by a fixing process (para. 0053). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include the fixing process of Suzushi for the purpose of allowing rapid analysis of the encoded surface and to minimize potential analysis errors.

Regarding claim 24, Knop teaches the invention as claimed but lacks reference to UV curing. Suzushi teaches the micro-relief pattern is formed by UV curing of a suitable material in contact with a master (para. 0099). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include the UV curing of Suzushi for the purpose of using a known method to create the pattern.

Regarding claims 25-32, Knop teaches the invention as claimed but lacks reference to the claimed systems. Suzushi teaches the use of the micro-relief pattern on various devices including optical security devices (para. 0075). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include optical device in the system of Suzushi for the purpose of authenticating important documents.

Claims 6 and 7 are rejected under 35 U.S.C. 103(a) as being unpatentable over Knop (US 4,251,137) in view of Nikolov (US 2004/0095637).

Knop teaches the invention as claimed but lacks reference to the thickness providing phase retardation. Nikolov teaches at least part of the optically anisotropic layer is selected having regard to the frequency of the intended illumination in use to provide phase retardation when appropriately viewed (para. 0062). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include the phase retardation of Nikolov for the purpose of differentiating the propagation of light based on polarization and/or wavelength to create a different image depending on the polarization or wavelength of incident light.

Claim 9 is rejected under 35 U.S.C. 103(a) as being unpatentable over Knop (US 4,251,137) in view of Admitted Prior Art.

Knop teaches the invention as claimed but lacks reference to the step distance greater than the pitch dimension. Admitted Prior Art teaches the encoding surface is stepped, whereby the thickness of the optically anisotropic layer is stepped by a step distance which is substantially greater than the structure pitch dimension thereby to provide regions of respective selective retardations (current specification para. 0033). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include the step distance as taught by the Admitted Prior Art for the purpose of providing polarization selectively to the encoding surface.

Claim 11 is rejected under 35 U.S.C. 103(a) as being unpatentable over Knop (US 4,251,137).

Knop teaches the anisotropic material varies (Figs. 3a-b) but lacks reference to linear varying. It is extremely well known in the art to have a linearly varying anisotropic material over the surface of a diffraction pattern. Official Notice is taken. It would have been obvious to one of ordinary skill in the art at the time the invention was made to have the Knop invention include the linearly varying anisotropic material as is known in the art for the purpose of matching a linearly shaped surface pattern.

Response to Arguments

Applicant's arguments, see Amendment, filed November 20, 2008, with respect to the rejection(s) of claim(s) 1 and 21 under Suzushi have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of Knop. Applicant amended the claim language to overcome the Suzushi reference. The Knop reference was added to teach the newly claimed combination.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to JOSHUA L. PRITCHETT whose telephone number is (571)272-2318. The examiner can normally be reached on Monday - Friday 7:00 - 3:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Stephone B. Allen can be reached on 571-272-2434. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Joshua L Pritchett/
Primary Examiner
Art Unit 2872